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Supporting Information

Fabrication of flexible and robust CdS composite photonic crystal films through melt-compression

Chengcai Wu^a, Qianyao Fang^a, Jiahao Li^a and Xin Su^{*a}

School of Material Science and Chemical Engineering, Ningbo University, Ningbo, Zhejiang, 315211, China.

Table S1. Recipes for preparing monodisperse CdS spheres with various diameters

$Cd(NO_3)_2 \cdot 4H_2O(g)$	TU (g)	PVP (g)	DEG (mL)	Diameter (nm)
11.10	2.74	5	360	130
11.72	2.89	5	360	150
12.34	3.04	5	360	170
12.96	3.20	5	360	190

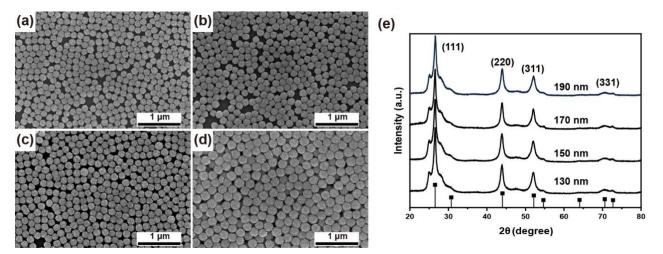


Figure S1. SEM images of monodisperse CdS spheres with different diameters: (a) 130 nm; (b) 150 nm; (c) 170 nm; (d) 190 nm; (e) XRD patterns of CdS spheres

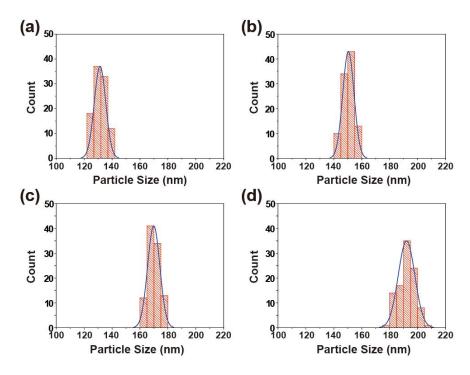


Figure S2. Size distribution of CdS spheres with various diameters: (a) 130 nm; (b) 150 nm; (c) 170 nm; (d) 190 nm;

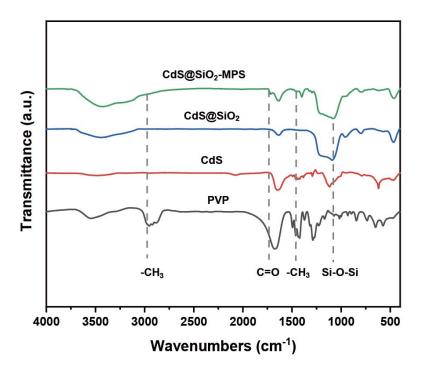


Figure S3. FTIR spectra of PVP, CdS spheres, CdS@SiO₂ spheres, CdS@SiO₂-MPS spheres

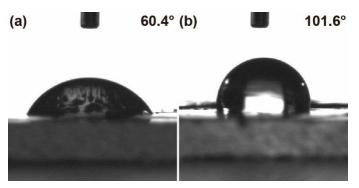


Figure S4. Optical images showing contact angles of water on the films of (a) CdS@SiO₂ spheres and (b) MPS-modified CdS@SiO₂ spheres

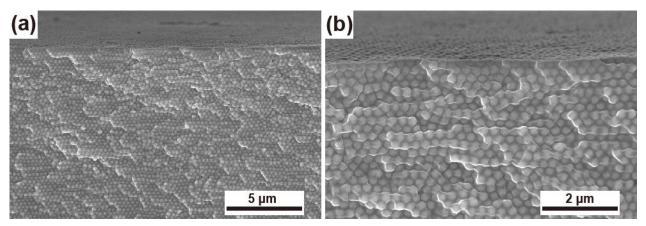


Figure S5. Cross-sectional SEM images near the surface of CdS/P(MMA-BA) composite PC films with different magnification times

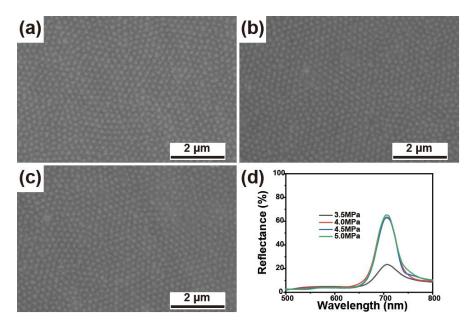


Figure S6. SEM images of composite PC films at various applied pressures using CdS@SiO₂@P(MMA-BA) spheres with 25 nm polymer shell as building blocks: (a) 4.0 MPa; (b) 4.5 MPa; (c) 5.0 MPa; (d) reflectance spectra of corresponding films. The films were fabricated at 80 °C for 5 min.

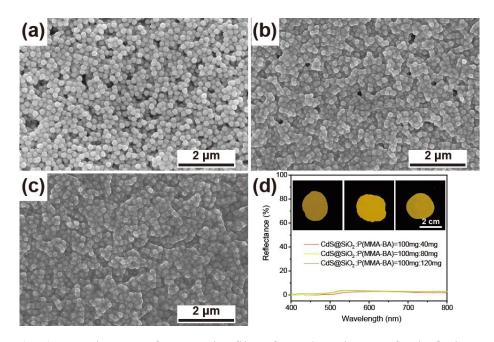


Figure S7. (a~c) SEM images of composite films from the mixture of CdS@SiO₂ spheres and P(MMA-BA) nanoparticles with different ratios; (d) reflectance spectrum of film a-c, the insets are the corresponding digital photographs.

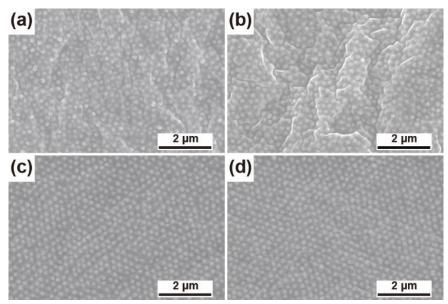


Figure S8. SEM images of compressed films at various conducting temperatures: (a) 60 °C; (b) 70 °C; (c) 80 °C; (d) 90 °C. The polymer shell thickness and applied pressure are 20 nm and 3.5 MPa, respectively.

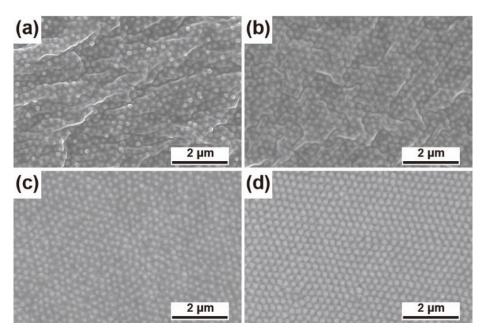


Figure S9. SEM images of compressed films at various applied pressures: (a) 0.5 MPa; (b) 1.5 MPa; (c) 2.5 MPa; (d) 3.5 MPa. The polymer shell thickness and conducting temperature are 20 nm and 80 °C, respectively.



Figure S10. Equipment for the washing process test

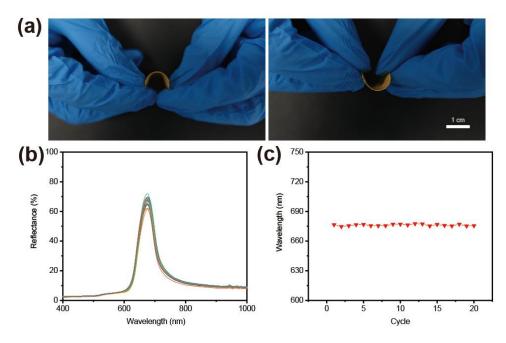


Figure S11. (a) Digital photographs demonstrating bending operations; (b) reflection spectra of the PC film after various cycles of bending; (c) peak positions of reflection spectra versus cycles

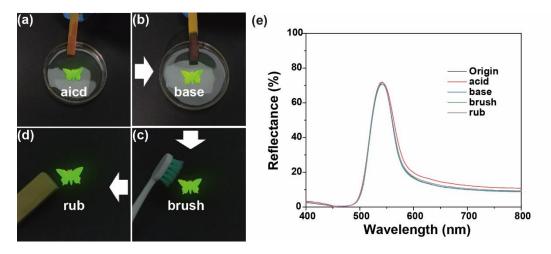


Figure S12. Digital photographs of a green butterfly-shaped composite film (a,b) soaked in acid solution (pH=2) and basic solution (pH=12) for 2 h; (c) brushed and (d) rubbed for 100 times; (e) reflectance spectra of the green film after certain treatment

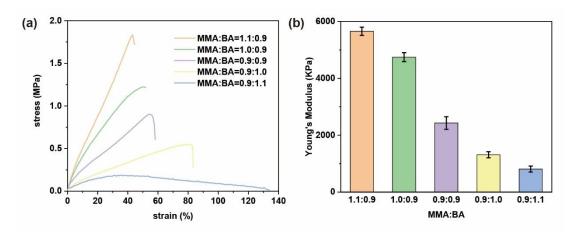


Figure S13. (a) Strain-stress curves and (b) Young's modulus of composite PC films with different polymer shell compositions;

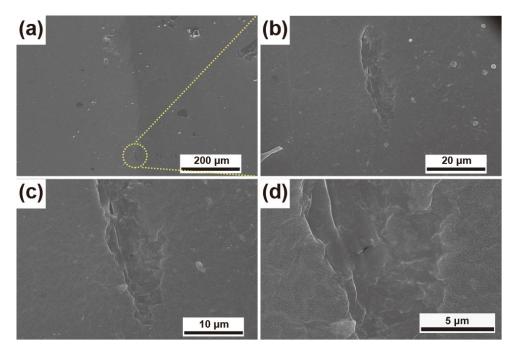


Figure S14. SEM images of the boundary of yellow and green pieces in a recombined pattern with different magnification times